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JC05 Rec'd PCT/PTO 01 AUG 2001  
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#51

In re the Application of

Shouji YAJIMA et al.

Application No.: 09/806,236

Docket No.: 109067

Filed: March 28, 2001

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NOV 21 2001

TC 1700

For: PRODUCTION OF SYNTHETIC SILICA GLASS AND THERMAL TREATMENT  
APPARATUS

**REQUEST FOR CORRECTION OF PALM RECORDS**

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Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

James A. Oliff  
Registration No. 27,075

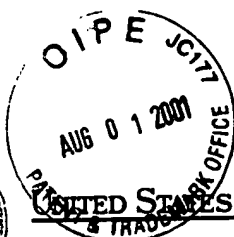
Joel S. Armstrong  
Registration No. 36,430

Date: August 1, 2001

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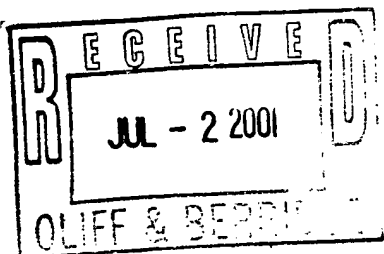


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APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLAIMS	IND CLAIMS
09/806,236	03/28/2001	1731	860	109067	22	6	2

 Oliff & Berridge  
 PO Box 19928  
 Alexandria, VA 22320


CONFIRMATION NO. 6948

FILING RECEIPT



\*OC000000006234651\*

Date Mailed: 06/27/2001

Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Customer Service Center. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

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TC 1700

## Domestic Priority data as claimed by applicant

THIS APPLICATION IS A 371 OF PCT/JP00/05412 08/11/2000

 Assignment for Published Patent  
 Application  
 NIKON CORPORATION

## Foreign Applications

JAPAN P1999-228197 08/12/1999

Projected Publication Date: N/A

Non-Publication Request: No

Early Publication Request: No

## Title

Production method

~~Method for preparation of synthetic vitreous silica and apparatus for heat treatment~~

glass

thermal

APPARATUS

## Preliminary Class

065